

Annamaria Gerardino. Degree in Physics (Quantum Optics) (1991) at "La Sapienza" University of Rome and PhD degree in Electronic Engineering (Nanofabrication) at University "Tor Vergata" of Rome (1997). She is a researcher at CNR since 1997 and she is in the team responsible of the electron beam lithography system installed at CNR-IFN. She is co-author of more than 90 papers published on international review with referee and she has given talks at international conferences and invited lectures at international institutions and schools. Her activity is mainly on the development of nanofabrication processes for photonic, biophotonic and spintronic devices among which photonic crystal based device and more recently microfluidic devices for cell on chip studies. She has been Scientific Responsible in FP6 Network of Excellence ePIXnet (European Network of Excellence on Photonic Integrated Component and Circuits) and FP6 Marie Curie Action, ProMiNaS Prototyping in the Micro and Nano Scale) and she is now involved in international and national projects. She is also in the Scientific committee of Micro and Nano Engineering (MNE) International Conference.